SMT screens and stencils obtained by Photochemical etching
Since many years we have optimised a technique for manufacturing SMT stencils by photochemical etching. This technique is founded on the accurate elaboration of gerber files and allows the compensation of shape defects and critical aspects typical of the chemical process, reducing them to the least. This technology is suitable for SMT printing applications for the components with pitch until 0.625 mm.

**Advantages**
- Cost-effectiveness
- Fair quality for most SMT applications
- Opportunity to produce half-etchings